IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Yasuhiko KASAMA et al. Conf. 9603

Application No. 10/585,245 Group 1792

Filed January 10, 2007

Examiner Marianne L. Padgett

ION IMPLANTATION SYSTEM AND ION IMPLANTATION SYSTEM

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

September 25, 2009

Sir:

In compliance with Rules 1.97 and 1.98, and in fulfillment of the duty of disclosure under Rule 1.56, the accompanying documents, copies of which are attached to this statement, are made of record on the enclosed Form PTO-1449.

A concise explanation of the relevance of these items is that these references were cited by the Korean Patent Office in the corresponding Korean Application filed July 9, 2007.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future submissions, to charge any underpayment or credit any overpayment to Deposit Account

Docket No. 8075-1099 Appln. No. 10/585,245

No. 25-0120 for any additional fees required under 37 C.F.R. \$ 1.16 or under 37 C.F.R. \$ 1.17.

Respectfully submitted,

YOUNG & THOMPSON

/Robert J. Patch/

Robert J. Patch, Reg. No. 17,355 209 Madison Street, Suite 500 Alexandria, VA 22314 Telephone (703) 521-2297 Telefax (703) 685-0573 (703) 979-4709

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